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Effect of oxygen vacancy segregation in Au or Pt/oxide hetero-interfaces on electronic structures

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We investigated the effects of oxygen vacancy segregation on electronic structures in the vicinity of hetero-interfaces between noble metals (Au and Pt) and yttria stabilized zirconia (YSZ) by performing first-principles calculations and Bader analysis. The density of states (DOS) of the Au/YSZ interface around the Fermi level is less than that of the Pt/YSZ interface, resulting from the lower density of Au-s and -p orbitals around the Fermi level compared with the higher density of Pt-d orbitals. Metal layers adjacent to the interface become negatively charged when the bonding oxygen layer contains a high concentration of oxygen vacancies. These results indicate that segregation of oxygen vacancies to Au or Pt/YSZ hetero-interfaces increase the electronic conductivity of Au or Pt atom layers at the interfaces.

1. Introduction

Tailoring a material's properties at the atomic/electronic level is a key step in the design of functional materials and devices. Notably, interfaces within and between materials are one of the important factors.^{1–3} For instance, it has been reported that the catalytic properties of metals can be altered by placing them in contact with different ferroelectric materials,^{4–8} and electronic and ionic mobility are changed at grain boundaries or hetero-interfaces in materials.^{9–13} Formation energies and segregation of point defects at grain boundaries or hetero-interfaces in oxide materials were also investigated using first-principles calculations.^{14,15} Electronic double layer (EDL) transistors^{16–19} are other examples of how interfaces can be tailored to obtain unexpected properties. EDL transistors contain interfaces between an ionic conductor and a semiconductor. Some semiconductors are reported to exhibit superconductivity when a voltage is applied to the ionic conductor from the gate.¹⁷ This phenomenon is thought to originate from charge injection into the semiconductor as a result of segregation of conductive ions in the ionic conducting crystal. Recently, Asano *et al.* observed conductivity modulation in Au thin films grown on a lithium ion conductor ($\text{Li}_{3-x}\text{La}_{2/3-x}\text{TiO}_3$) substrate under an EDL gate bias.²⁰

The above results suggest that segregation of conductive ions in ionic conductors can increase the electronic conductivity of metal layers adjacent to hetero-interfaces by applying a voltage

to the ionic conductor. However, these mechanisms have not been clearly revealed from the theoretical viewpoint. In this study, we investigate the electronic structure of hetero-interfaces between a metal and an oxide-ion conductor, using two different structural models, one with and one without segregation of oxide ion vacancies, using first-principles calculation techniques. In particular, we focus on the effects of oxygen vacancy segregation on electronic states of atoms at interfaces between yttria stabilized zirconia (YSZ) and a catalytic metal, either Pt or Au, and metal(111)/YSZ(111) hetero-interface systems²¹ are considered.

2. Computational methodology

First-principles calculations were performed on Pt(111)/YSZ(111) and Au(111)/YSZ(111) hetero-interface systems using the projector augmented-wave (PAW) method^{22,23} implemented in the VASP code.^{24,25} The Perdew–Burke–Ernzerhof functional²⁶ was used for the exchange–correlation term, and plane-wave cutoff energies were set to 400 eV. Integration in reciprocal space was performed using $5 \times 5 \times 1$ *I*-centered grids. The total energies were minimized until the energy convergences were less than 10^{-5} eV during self-consistent cycles and residual atomic forces in the optimized structures were less than 0.02 eV \AA^{-1} . Spin polarization was considered. Bader charges^{27,28} of Pt and Au atoms were calculated after geometry optimization to compare the electronic states of Au or Pt atoms between the different models.

Crystals of Pt, Au, and YSZ all belong to cubic space group $Fm\bar{3}m$, so their (111) surfaces all exhibit hexagonal symmetry. Interface models were thus constructed by joining supercells of hexagonal slabs of metal and oxide to minimize lattice misfit. Specifically, a 4×4 (111) metal slab was placed adjacent to

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a non-polar O-terminated 3×3 (111) cubic-ZrO₂ slab in each case. The hetero-interface models contained 6 atomic layers of metal slabs and 6 ZrO₂-block layers of cubic-ZrO₂ slabs. Dimensions of YSZ slab were determined by interpolating the volume of several YSZ models with different yttria contents constructed from special quasi-random structures.²⁹ The lattice constant of YSZ was calculated as $a = 5.214 \text{ \AA}$, which is close to the experimental lattice constant of Y_{0.214}Zr_{0.786}O_{1.866}, 5.148 \AA .³⁰ The metal slab was expanded parallel to the interface so that the dimensions of the metal and YSZ slab models become equal. For that purpose, the lattice constant of the metal used for the slab model, $a_{\text{metal_slab}}$, is set to be 3.933 \AA . The calculated lattice constants of metal bulk, $a_{\text{metal_bulk}}$, were 4.148 \AA for Au and 3.963 \AA for Pt in conventional fcc cell.

The lattice mismatches, $\Delta = a_{\text{metal_slab}}/a_{\text{metal_bulk}}$, were -5.2% for Au and -0.8% for Pt. The metal slab was then systematically moved relative to the ZrO₂ slab both parallel and perpendicular to the interface until an energy minimum was found upon relaxing the atom positions while keeping the cell dimensions fixed. In each ZrO₂ layer, two Y atoms were placed on non-neighboring sites and one oxide ion removed, so that each model contained 96 M (M = Pt, Au) atoms, 42 Zr atoms, 12 Y atoms, and 102 O atoms, giving a total of 252 atoms in each simulation cell. This corresponds to a composition of Zr₇Y₂O₁₇, or 11.1 mol% Y₂O₃-doped ZrO₂, for the YSZ slab, which is close to the composition commonly used for cubic-stabilized YSZ oxide ion conductors.³¹

Two different oxygen vacancy distributions in the YSZ slab were considered. Fig. 1 illustrates the two models, drawn using the VESTA code.³² In the first model, vacancies were distributed evenly throughout the YSZ crystal with one O vacancy in each layer on second nearest neighbor sites to Y atoms.³³ In the

second model, three oxygen vacancies far from one of the hetero-interfaces were moved in the O layer adjacent to this interface. Four O vacancies were placed in the O layer adjacent to one of the hetero-interfaces, one in the fourth O layer below this interface, and one in the sixth O layer below this interface. All other O layers (including that adjacent to the other interface) were fully occupied. In the segregated vacancy model, layers in the metal crystal were labeled 1 to 6, where layer 1 is adjacent to the vacancy-segregated layer in the YSZ slab, and layer 6 is next to the fully-occupied O layer on the opposite side.

3. Results and discussions

Fig. 2 shows plots of the total and projected electronic densities of states (DOS) corresponding to the spin-up state of segregated vacancy models for the two systems. The DOSs of spin-up and spin-down states were same in our models. The Fermi level is set at 0 eV. The Fermi level is located in the band gap of YSZ and consists of 6s and 6p orbitals of Au in the case of the Au/YSZ system. Small components of Au 5d orbitals also exist around the Fermi level. In contrast, large DOS of 5d orbitals of Pt traverses the Fermi level in the case of the Pt/YSZ system. In other words, the DOS near the Fermi level in the Au/YSZ system is less than that in the Pt/YSZ system.

Bader charge analysis was carried out to examine the distribution of charge within the metal slabs. Fig. 3 shows Bader charges of metal atoms as a function of position between interfaces in each model. In the bulk region of metal slabs (layers 2 to 5) Bader charges of metal atoms were similar for both the segregated vacancy model and the non-segregated vacancy model. In contrast, Bader charges of metal atoms in layers adjacent to the interfaces (layers 1 and 6) were very different, as their coordination/bonding environments are very different to those of atoms in the bulk. Specifically, in the segregated vacancy models, the Bader charges of metal atoms in layer 1 are much larger than those in layer 6. This is because oxygen vacancies in YSZ have effective positive charges, inducing more electrons to accumulate on atoms in the neighboring metal layer, layer 1. In contrast, the metal atoms in layer 6 lose more of their electrons on account of the larger population of negatively charged oxygen atoms in the neighboring layer to which they are bonded. Overall, charge neutrality is maintained.

To examine the differences in electronic states between metal atoms in the segregated and non-segregated vacancy models in more detail, we calculated the average electron density of each metal layer normalized to the cross-sectional area. Fig. 4 shows the differences of the electron densities between metal atoms in the segregated and non-segregated vacancy models, $\Delta\rho_{\text{el}} = \rho_{\text{el}}^{\text{segregated}} - \rho_{\text{el}}^{\text{non-seg}}$, where $\rho_{\text{el}}^{\text{segregated}}$ and $\rho_{\text{el}}^{\text{non-seg}}$ are the normalized average Bader charges of each layer in the segregated and non-segregated vacancy models, respectively. The values for layers 2 to 5 are almost zero. However, the metal layer adjacent to the vacancy-rich O layer in the segregated vacancy model (metal layer 1) is negatively charged (-0.31 C m^{-2} for Pt and -0.26 C m^{-2} for Au), while that adjacent to the fully occupied O layer (metal layer 6) is positively

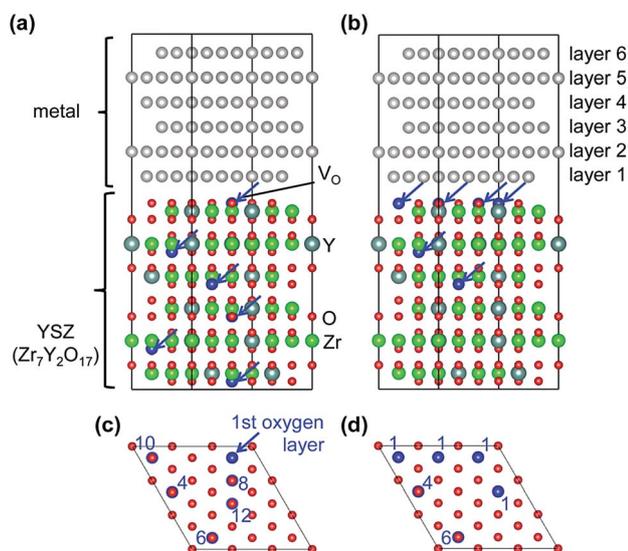


Fig. 1 Structure models of planar incoherent (111) hetero-interfaces between metals (Pt or Au) and YSZ. (a) Non-segregated oxygen vacancy model, and (b) segregated oxygen vacancy model. Blue arrows mean oxygen vacancies. Numerical values in (c) and (d) represent the number of the oxygen layer counted from the interface in the middle in (a) and (b).



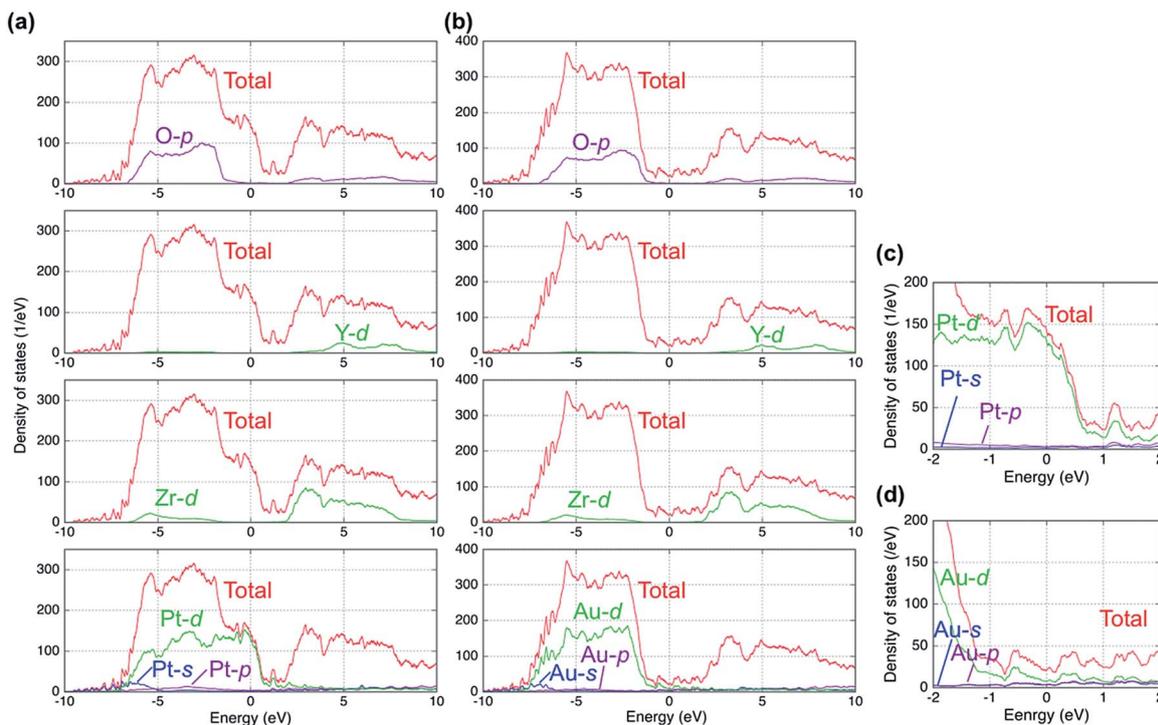


Fig. 2 Calculated total and projected densities of states (DOS) for segregated vacancy models of (a) Pt(111)/YSZ(111) and (b) Au(111)/YSZ(111) interface systems. Magnified views of the projected DOS of (c) Pt and (d) Au near the Fermi level.

charged (0.33 C m^{-2} for Pt and 0.24 C m^{-2} for Au). These charges correspond to electron areal densities of $1.9 \times 10^{14} \text{ cm}^{-2}$, $1.6 \times 10^{14} \text{ cm}^{-2}$, $2.1 \times 10^{14} \text{ cm}^{-2}$ and $1.5 \times 10^{14} \text{ cm}^{-2}$, respectively. The changes in electronic charge on Pt and Au atoms in layers 1 and 6 are almost the same. This is mainly because oxygen concentrations in the YSZ layers adjacent to the metal slabs are the same for both models. Since the averages of Bader charges of oxygen atoms in each layer are almost the same for segregated and non-segregated vacancy models, the valence states of oxygen atoms do not affect the charge

accumulation in the metal slabs. Such electronic charge accumulation in response to segregation of mobile ionic species is expected to result in an increase in the electronic conductivity of the metal layer, as reported for all-solid-state EDL transistors in (ref. 20). In addition, the metal slabs are simultaneously in contact with net positively- and net negatively-charged YSZ surfaces in the segregated vacancy hetero-interface model in this study. This periodicity of our hetero-interface models means that the change in Fermi level related on the catalytic properties in the vicinity of the biased metal-insulator

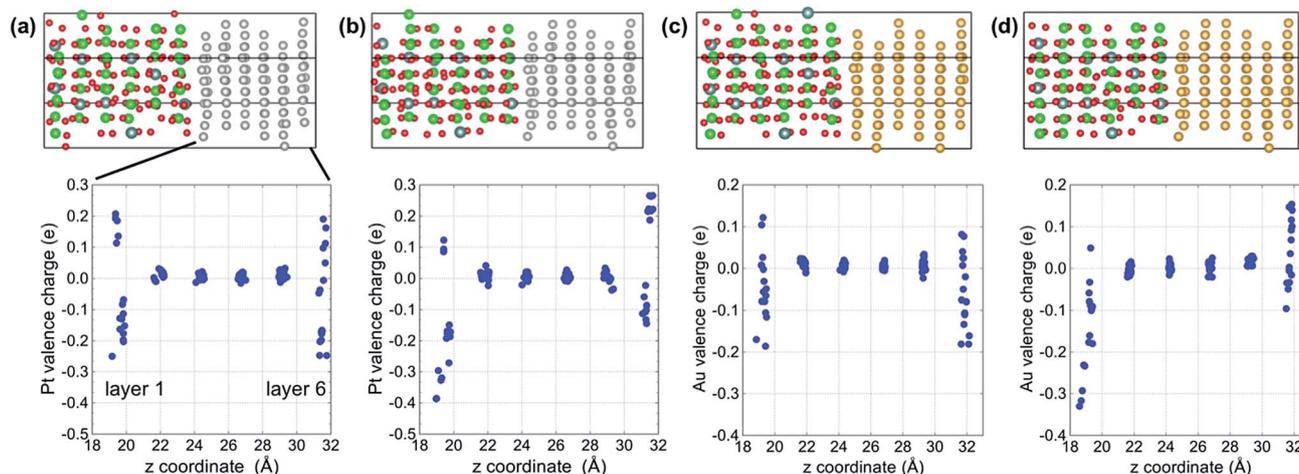


Fig. 3 Bader charges of each metal atom as a function of position between interfaces. (a) Non-segregated vacancy model of Pt/YSZ, (b) segregated vacancy model of Pt/YSZ, (c) non-segregated vacancy model of Au/YSZ, and (d) segregated vacancy model of Au/YSZ.



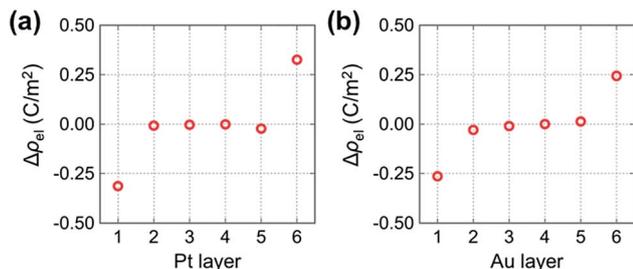


Fig. 4 Difference in electron density between metal layers in the segregated and non-segregated vacancy models of (a) Pt/YSZ and (b) Au/YSZ.

interfaces cannot be determined quantitatively from our calculations. However, it is reasonable to assume that the effect of the bias on Fermi level of Au will be greater than that for Pt, because Au has lower DOS around the Fermi level than Pt (Fig. 2), *i.e.*, the Fermi level shift induced by charge accumulation is larger in the case of Au/YSZ.

4. Summary

Planar interfaces between YSZ and metals Pt and Au have been computationally examined using first-principles calculations and Bader charge analysis within the framework of density functional theory. The DOS of the Au/YSZ interface around the Fermi level is lower than that of the Pt/YSZ interface on account of the lower density of Au 6s, 6p and 5d orbitals compared with the Pt 5d orbitals. Bader analysis revealed that the metal layers adjacent to the interface become positively or negatively charged when the bonding oxygen layer is rich or poor in oxygen vacancies, respectively. Metal atoms adjacent to an oxygen vacancy-rich interface were found to have higher electron densities than those adjacent to vacancy-free interfaces as a result of charge accumulation. The results indicate that segregation of oxygen vacancies to Au or Pt/YSZ hetero-interfaces alters the electronic conductivity of the layer of Au or Pt atoms adjacent to the interface relative to those in bulk metal.

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Notes and references

- 1 J. Maier, *Nat. Mater.*, 2005, **4**, 805–815.
- 2 J. Maier, *J. Electroceram.*, 2015, **34**, 69–73.
- 3 K. Garrity, A. M. Kolpak, S. Ismail-Beigi and E. I. Altman, *Adv. Mater.*, 2010, **22**, 2969–2973.
- 4 H. L. Stadler, *Phys. Rev. Lett.*, 1965, **14**, 979–981.
- 5 C. Park and R. T. K. Baker, *J. Phys. Chem. B*, 2000, **104**, 4418–4424.

- 6 C. Park and R. T. K. Baker, *Chem. Mater.*, 2002, **14**, 273–280.
- 7 N. Saito, Y. Yukawa and Y. Inoue, *J. Phys. Chem. B*, 2002, **106**, 10174–10178.
- 8 A. M. Kolpak, I. Grinberg and A. M. Rappe, *Phys. Rev. Lett.*, 2007, **98**, 3–6.
- 9 Y. Chiang, E. B. Lavik, I. Kosacki, H. L. Tuller and J. Y. Ying, *Appl. Phys. Lett.*, 1996, **69**, 185–187.
- 10 S. Kim and J. Maier, *J. Electrochem. Soc.*, 2002, **149**, J73–J83.
- 11 P. Lupetin, G. Gregori and J. Maier, *Angew. Chem., Int. Ed.*, 2010, **49**, 10123–10126.
- 12 I. Denk, J. Claus and J. Maier, *J. Electrochem. Soc.*, 1997, **144**, 3526–3536.
- 13 N. Sata, K. Eberman, K. Eberl and J. Maier, *Nature*, 2000, **408**, 946–949.
- 14 B. Liu, V. R. Cooper, Y. Zhang and W. J. Weber, *Acta Mater.*, 2015, **90**, 394–399.
- 15 D. S. Aidhy, B. Liu, Y. Zhang and W. J. Weber, *J. Phys. Chem. C*, 2014, **118**, 30139–30144.
- 16 T. Tsuchiya, K. Terabe and M. Aono, *Appl. Phys. Lett.*, 2013, **103**, 3–7.
- 17 K. Ueno, H. Shimotani, H. Yuan, J. Ye, M. Kawasaki and Y. Iwasa, *J. Phys. Soc. Jpn.*, 2014, **83**, 32001.
- 18 H. Nakayama, J. Ye, T. Ohtani, Y. Fujikawa, K. Ando, Y. Iwasa and E. Saitoh, *Appl. Phys. Express*, 2012, **5**, 23002.
- 19 K. Taniguchi, T. Fukamichi, K. Itaka and H. Takagi, *Adv. Funct. Mater.*, 2015, **25**, 3043–3048.
- 20 T. Asano, Y. Kaneko, A. Omote, H. Adachi and E. Fujii, *ACS Appl. Mater. Interfaces*, 2017, **9**, 5056–5061.
- 21 G. Beck, H. Fischer, E. Mutoro, V. Srot, K. Petrikowski, E. Tchernychova, M. Wuttig, M. Rühle, B. Luerßen and J. Janek, *Solid State Ionics*, 2007, **178**, 327–337.
- 22 P. E. Blöchl, *Phys. Rev. B: Condens. Matter Mater. Phys.*, 1994, **50**, 17953–17979.
- 23 G. Kresse and D. Joubert, *Phys. Rev. B: Condens. Matter Mater. Phys.*, 1999, **59**, 1758–1775.
- 24 G. Kresse and J. Hafner, *Phys. Rev. B: Condens. Matter Mater. Phys.*, 1993, **47**, 558–561.
- 25 G. Kresse and J. Furthmüller, *Phys. Rev. B: Condens. Matter Mater. Phys.*, 1996, **54**, 11169–11186.
- 26 J. P. Perdew, K. Burke and M. Ernzerhof, *Phys. Rev. Lett.*, 1996, **77**, 3865–3868.
- 27 G. Henkelman, A. Arnaldsson and H. Jonsson, *Comput. Mater. Sci.*, 2006, **36**, 354–360.
- 28 M. Yu and D. R. Trinkle, *J. Chem. Phys.*, 2011, **134**, 1–8.
- 29 A. Zunger, S. Wei, L. Ferreira and J. Bernard, *Phys. Rev. Lett.*, 1990, **65**, 353–356.
- 30 M. Morinaga, J. B. Cohen and J. Faber Jr, *Acta Crystallogr., Sect. A: Cryst. Phys., Diffr., Theor. Gen. Crystallogr.*, 1979, **35**, 789–795.
- 31 P. Knauth and H. L. Tuller, *J. Am. Ceram. Soc.*, 2004, **85**, 1654–1680.
- 32 K. Momma and F. Izumi, *J. Appl. Crystallogr.*, 2008, **41**, 653–658.
- 33 A. Predith, G. Ceder, C. Wolverton, K. Persson and T. Mueller, *Phys. Rev. B: Condens. Matter Mater. Phys.*, 2008, **77**, 144104.

